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Number of Pages (including this page)

Date:

May 25, 2005

To:

Trinh, Hoa B.-2814

Location:

United States Patent and Trademark Office

Fax No.:

From:

James A. Lamb - 38,529

Subject:

Batch No.

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MESSAGE:

Enclosed herewith, please find a Restriction Election for filing in the below-identified application.

PLEASE GIVE THESE PAPERS TO:

EXAMINER: Trinh, Hoa B.

SERIAL NO.: 10/745,589 (0/743789 ME)

FILED: 12/22/2003

INVENTOR: DUNN ET AL.

3 H

	Application Number	10/745;589	
	Filing Date	12/22/2003	
TRANSMITTAL	First Named Inventor	Dunn et al.	
FORM	Group Art Unit	2814	
(to be used for all correspondence after initial মানু)	Examiner Name	Trinh, Hoa B.	
Total Number of Pages in this Submission	Attorney Docket Number	CML01206AT	
ENCLOSURES (check all that apply)			
Fee Transmittal Form	Assignment Papers (for an Application)		nication to Group
Fee Attached	Drawing(s)		Communication to Board als and Interferences
Amendment/Reply	Licensing-Related paper	ers Appeal C	Communication to Group lotice, Brief, Reply Brief)
After Final	Petition	Proprietary Information	
Affidavits/Declaration(s)	Petition to Convert to a Provisional Application	Status Le	tter with appropriate copies
Extension of time Request	Power of Attorney, Revoc	Rosponse to Restriction Requirement	
Express Abandonment Request	Address	Assoc	clate Power of Attorney
Information Disclosure Statement	Terminal Disclaimer		
Certified Copy of Priority Documents			· · · · · · · · · · · · · · · · · · ·
Response to Missing Parts/	CD, Number of CDs		
Incomplete Application	Remarks		.*
Response to Missing Parts Under 37 CFR 1.52 or 1.53			
SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT			
Firm or James A. Lamb		Registration No.	38,529
Signature Va A L			
Date 05-25-2005			
CERTIFICATE OF MAILING			
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MAY 2 5 2005

DOCKET NO.: CML01206AT

UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT(S)

GROUP ART UNIT:

2814

APPLN. NO.:

10/745,589 10/743589 14

EXAMINER:

Trinh, Hoa B.

FILED: TITLE:

12/22/2003

TWO LAYER PATTERNED RESISTOR

05/11/2005

Conflicate of Transmission under 37 CFR 1.8

I hereby cordly that this

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents Alexandria, VA 22313-1450

Sir:

This paper is in response to the restriction requirement in the Office Action mailed 05/11/2005.

<u>REMARKS</u>

In response to the restriction requirement mailed on 5/11/2005, applicants elect Group II, claims 7-15 with traverse. Any fees should be charged to deposit account 502117.

Applicants respectfully traverse the Examiner's argument for the restriction, for the following reasons.

Examiner states: "...the product can be made by another and materially different process such that the process includes the step of etching two conductive layers to form conductive end terminations on the substrate, instead of patterning the conductive end terminations."

The well known meaning of "patterning" to those of ordinary skill in the art of fabricating electronic circuits on substrates, as used in applicants' claimed step of "patterning two conductive end terminations on the substrate", when applied to the fabrication of conductive terminations by etching includes the sub-steps of both lithography and etching.

This meaning is further supported by the first definition of the transitive verb "pattern" that is shown below, taken from The American Heritage® Dictionary of the English Language: Fourth Edition. 2000, which is "to make, mold, or design by following a pattern".

By this definition and by the meaning that is well known to those of ordinary skill in the art of fabricating electronic circuits on substrates, other processes used to form conductive end terminations or resistor patterns necessarily have a patterning step.

pattern

SYLLABICATION: pat-tern

PRONUNCIATION: Spatem

NOUN: 1a. A model or original used as an archetype. b. A person or thing considered worthy of imitation. 2. A plan, diagram, or model to be followed in making things: a dress pattern. See synonyms at ideal. 3. A representative sample; a specimen. 4a. An artistic or decorative design: a paisley pattern. See synonyms at figure. b. A design of natural or accidental origin: patterns of bird formations. 5. A consistent, characteristic form, style, or method, as: a. A composite of traits or features characteristic of an individual or a group: one's pattern of behavior. b. Form and style in an artistic work or body of artistic works. 6a. The configuration of gunshots upon a target that is used as an indication of skill in shooting. b. The distribution and spread, around a targeted region, of spent shrapnel, bomb fragments, or shot from a shotgun. 7. Enough material to make a complete garment. 8. A test pattern. 9. The flight path of an aircraft about to land: a flight pattern.

10. Football A pass pattern.

VERB: Inflected forms: pat-terned, pat-tern-ing, pat-terns

TRANSITIVE 1. To make, mold, or design by following a pattern: We patterned this VERB: plan on the previous one. My daughter patterned her military career

after her father's. 2. To cover or ornament with a design or pattern.

INTRANSITIVE To make a pattern.

VERB:

ETYMOLOGY: Middle English patron, from Old French. See patron.

SEND CORRESPONDENCE TO:

Motorola, Inc. Intellectual Property Section Law Department 1303 E. Algonquin Road Schaumburg, IL 60196 Respectfully submitted,

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